

IN THE SPECIFICATION

Please amend the paragraph on page 10, lines 16-19 as follows:

-- Due to the presence of a recess facing the layer 35, the distance between the layer 35 and the nearest optical surface may be larger than approximately 10  $\mu\text{m}$ , for instance larger than 15  $\mu\text{m}$ , 30  $\mu\text{m}$  or even 100  $\mu\text{m}$ , to increase the insensitivity to tolerances and to further reduce the risk of ~~contact~~ contact between the layer and an optical surface.--.

Please amend the paragraph on page 13, line 31 to page 14, line 8 as follows:

-- Figs. 4 and 5 show a distal end portion of a second example 109 of a lens system for devices such as the devices shown in Figs. 1 and 9. The lens system 109 according to this example includes a housing 161, a lens 159 nearest to the layer 5 on the substrate 3. According to this example, the recess 192 is bound by a concave portion of the surface 163 of the lens 159 nearest to the spot 111-11 on the layer 5 to which the beam of radiation 107 is directed. This allows to obtain the liquid retaining characteristics of a recess in combination with a relatively uniform flow pattern throughout the portion 194 of the interspace 153 through which radiation 107 passes to the spot 11. In particular, a uniform pattern of flow velocity gradients in the interspace 153 is obtained. In turn, the relatively uniform flow pattern is advantageous to avoid inducing vibrations and for

obtaining a continuous uniform supply of fresh liquid and thereby a uniform, steady liquid temperature. These effects are both advantageous for avoiding optical disturbance of the radiation beam 107.--.